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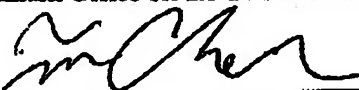
**Applicant:** Ralph C. Struthers; David B. Chang; Reza Toossi; Sion Ahdout; Lijuan Li; Robert G. Palomba  
**Assignee:** EnerNext, LCC  
**Title:** Method for Sorption and Desorption of Molecular Gas Contained by Storage Sites of Nano-Filament Laded Reticulated Aerogel (As Amended)  
**Serial No.:** 10/666,663 **Filing Date:** September 18, 2003  
**Examiner:** Ling Siu Choi **Group Art Unit:** 1713  
**Docket No.:** M-15154US **Confirmation No.:** 8992

Irvine, California  
 December 14, 2004

Facsimile: 703-872-9306  
 Mail Stop Amendment  
 Commissioner for Patents  
 P.O. Box 1450  
 Alexandria, VA 22313-1450

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Tom Chen, Reg. No. 42,406

Total No. of Pages: 15 (including this page)

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Serial No. 10/666,663

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Applicant(s): Ralph C. Struthers; David B. Chang; Reza Toossi; Sion Ahdout; Lijuan Li;  
Robert G. Palomba  
Assignee: EnerNext, LCC  
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Serial No.: 10/666,663 Filing Date: September 18, 2003  
Examiner: Ling Siu Choi Group Art Unit: 1713  
Docket No.: M-15154US Confirmation No.: 8992

Dear Sir:

Transmitted herewith are the following documents in the above-identified application:

- (1) Certification of Facsimile Transmission (1 page);
- (2) This Transmittal Letter (1 page);
- (3) Petition for Extension of Time - 3 months (1 page); and
- (4) Response to Office Action (11 pages).

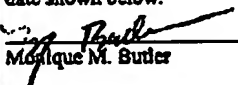
- ☐ No additional fee is required.  
☒ The fee has been calculated as shown below:

**CLAIMS AS AMENDED**


	Claims Remaining After Amendment		Highest No. Previously Paid For		Present Extra	Rate	Additional Fee
Total Claims	11	Minus	20	=	0	x \$ 25.00	\$ - 0 -
Independent Claims	2	Minus	3	=	0	x \$ 100.00	\$ - 0 -
<input type="checkbox"/> Fee of \$150.00 for the first filing of one or more multiple dependent claims per application							\$
<input type="checkbox"/> Information Disclosure Statement							\$

Application No.: 10/666/663  
Struthers et al.  
M-15154 US

<b>Total additional fee for this Amendment:</b>		\$	- 0 -
<input checked="" type="checkbox"/> Petition for Extension of Time is hereby requested (3 months).		\$	510
<input checked="" type="checkbox"/> Please charge our Deposit Account No. 50-2257 in the amount of		\$	510
<input checked="" type="checkbox"/> Also, charge any additional fees required and credit any overpayment to our Deposit Account No. 50-2257			

Certification of Facsimile Transmission	
I hereby certify that this paper is being facsimile transmitted to the U.S. Patent and Trademark Office on the date shown below.	
 Monique M. Butler	December 14, 2004 Date of Signature

Respectfully submitted,

  
Tom Chen  
Attorney for Applicants  
Reg. No. 42,406